

Supplemental Material for “Electronic and magnetic properties modulated by nonvolatile switching in the multiferroic $\text{Cr}_2\text{Cl}_3\text{S}_3/\text{Ga}_2\text{O}_3$ van der Waals heterostructure”

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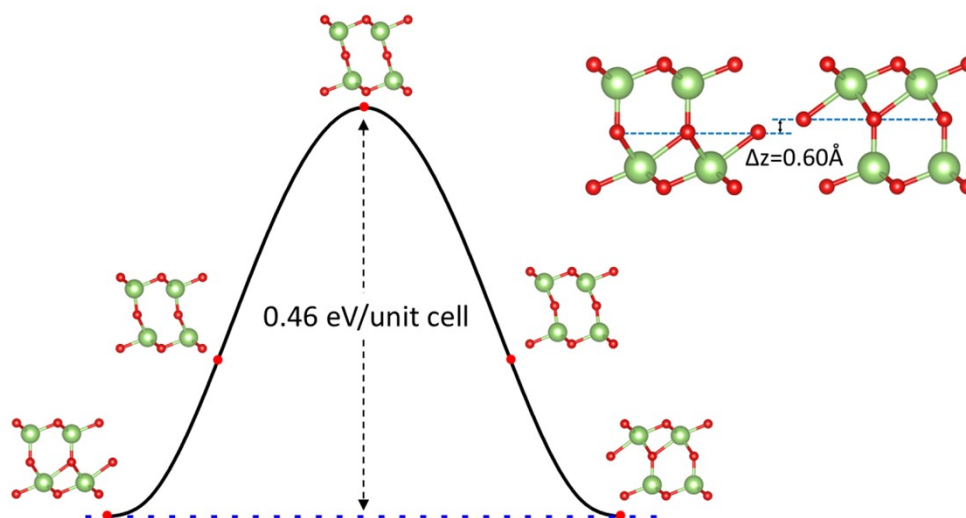


Fig. S1 The Kinetic pathway of polarization reversal process and ionic displacement (Δz) from $P\uparrow$ to $P\downarrow$ for Ga_2O_3 monolayer.

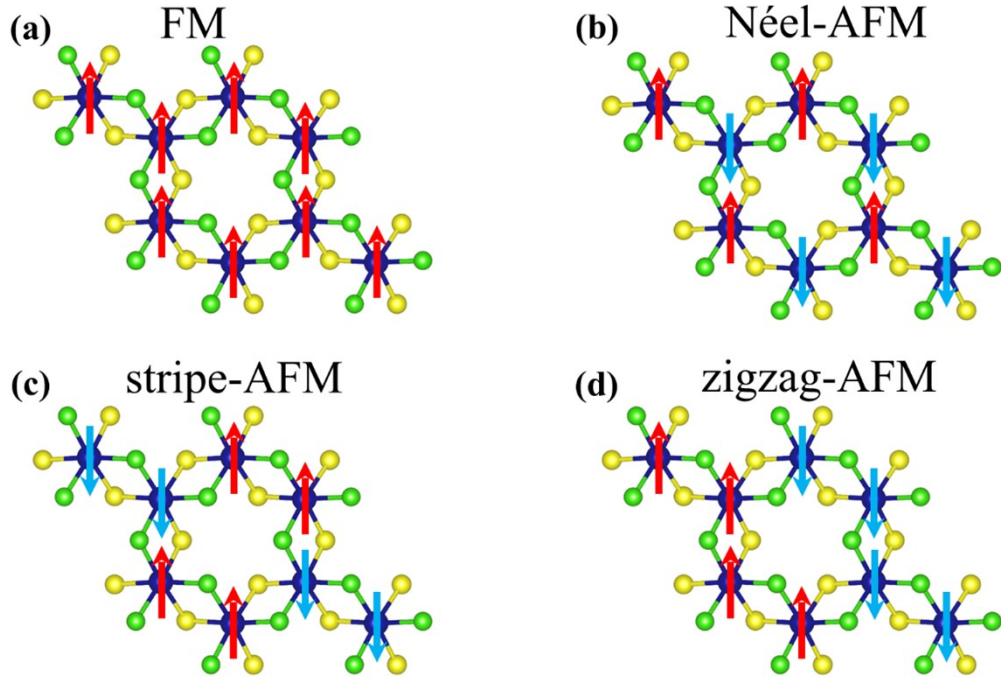


Fig. S2 (a) FM configuration, and the three AFM configurations: (b) Néel-AFM (nAFM), (c) stripe-AFM (sAFM), (d) zigzag-AFM (zAFM) states considered for $\text{Cr}_2\text{Cl}_3\text{S}_3$ monolayer.

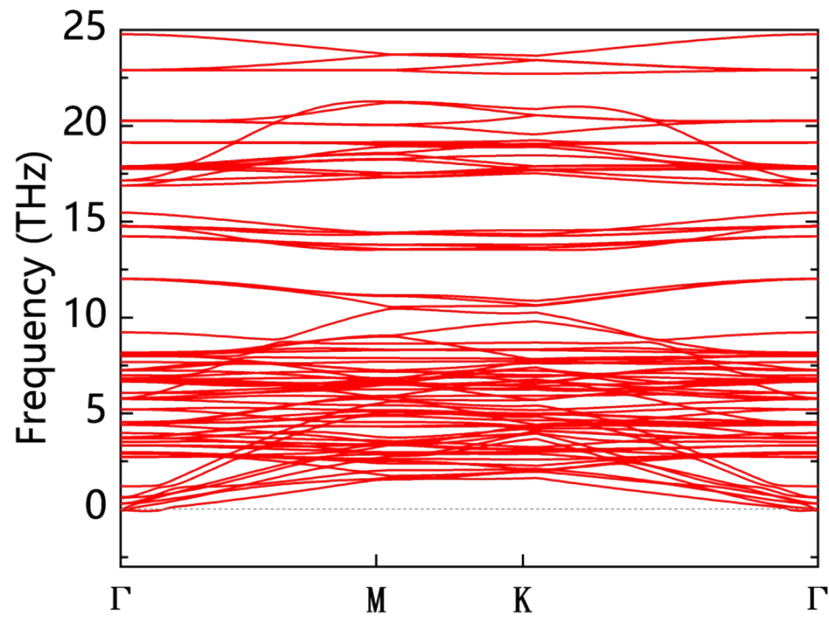


Fig. S3 Phonon dispersion for the $\text{Cr}_2\text{Cl}_3\text{S}_3/\text{Ga}_2\text{O}_3$ heterostructure.

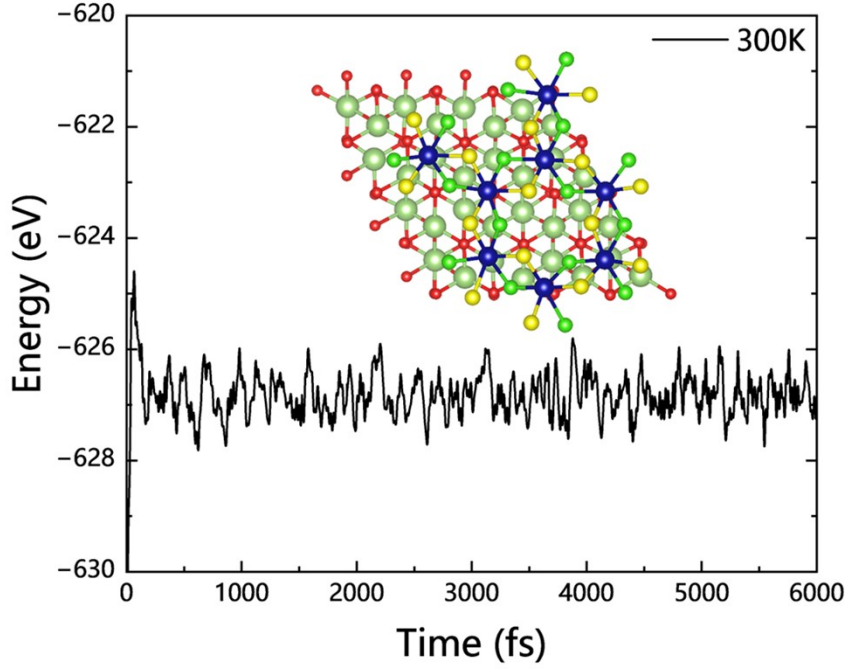


Fig. S4 Fluctuation of total energy and the final structure of $\text{Cr}_2\text{Cl}_3\text{S}_3/\text{Ga}_2\text{O}_3$ heterostructure after 6000 fs at 300 K from AIMD simulations.

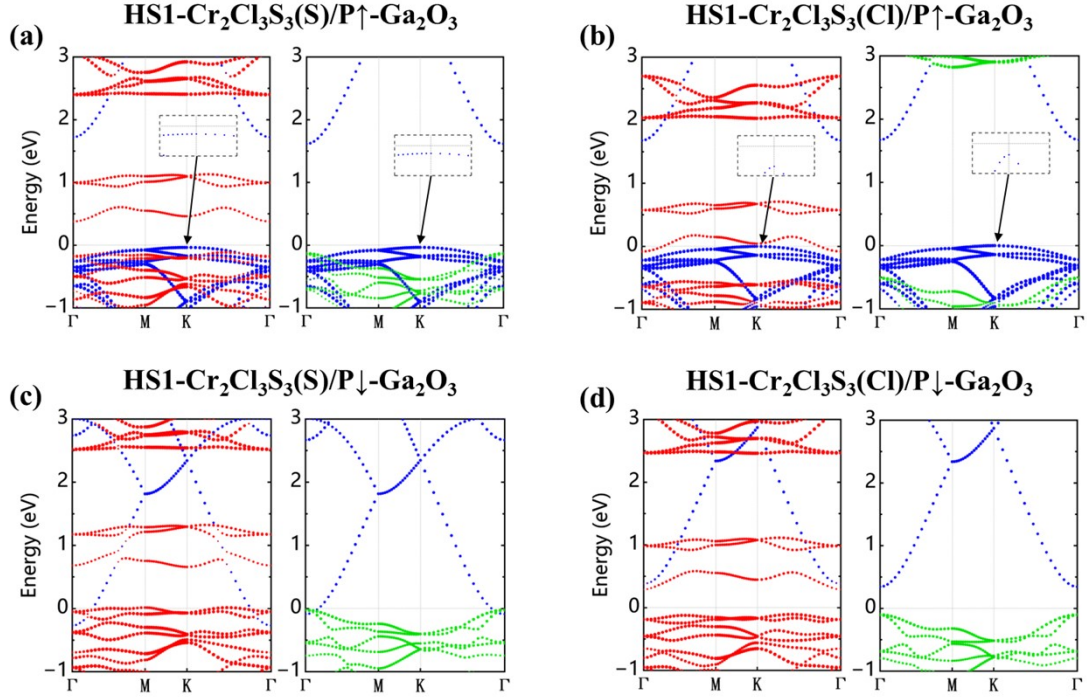


Fig. S5 Band structures of the four heterostructures (a) $\text{HS1-Cr}_2\text{Cl}_3\text{S}_3(\text{S})/\text{P}\uparrow\text{-Ga}_2\text{O}_3$, (b) $\text{HS1-Cr}_2\text{Cl}_3\text{S}_3(\text{Cl})/\text{P}\uparrow\text{-Ga}_2\text{O}_3$, (c) $\text{HS1-Cr}_2\text{Cl}_3\text{S}_3(\text{S})/\text{P}\downarrow\text{-Ga}_2\text{O}_3$ and (d) $\text{HS1-Cr}_2\text{Cl}_3\text{S}_3(\text{Cl})/\text{P}\downarrow\text{-Ga}_2\text{O}_3$, respectively. Red and green dots denote the spin-up and spin-down contributions of $\text{Cr}_2\text{Cl}_3\text{S}_3$, respectively, while blue dots represent the spin-degenerate projected bands of Ga_2O_3 .



Fig. S6 Band structures of the four heterostructures (a) HS2-Cr₂Cl₃S₃(S)/P↑-Ga₂O₃, (b) HS2-Cr₂Cl₃S₃(Cl)/P↑-Ga₂O₃, (c) HS2-Cr₂Cl₃S₃(S)/P↓-Ga₂O₃ and (d) HS2-Cr₂Cl₃S₃(Cl)/P↓-Ga₂O₃, respectively. Red and green dots denote the spin-up and spin-down contributions of Cr₂Cl₃S₃, respectively, while blue dots represent the spin-degenerate projected bands of Ga₂O₃.

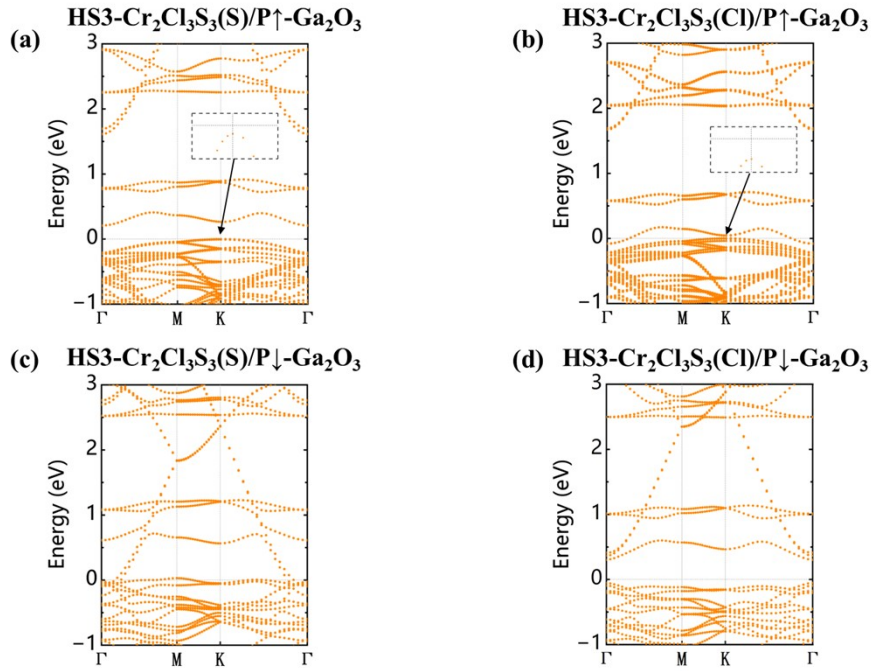


Fig. S7 Band structures of the four heterostructures with SOC effect: (a) HS3-Cr₂Cl₃S₃(S)/P↑-Ga₂O₃, (b) HS3-Cr₂Cl₃S₃(Cl)/P↑-Ga₂O₃, (c) HS3-Cr₂Cl₃S₃(S)/P↓-Ga₂O₃, and (d) HS3-Cr₂Cl₃S₃(Cl)/P↓-Ga₂O₃, respectively.

Table SI Work functions (Φ_1 and Φ_2), spin-up and spin-down conduction band offset ($\Delta E_{CBO}^{\uparrow/\downarrow}$), and valence band offsets ($\Delta E_{VBO}^{\uparrow/\downarrow}$) of the four HS3-Cr₂Cl₃S₃/Ga₂O₃ heterostructures

Configuration	Φ_1 (eV)	Φ_2 (eV)	$\Delta E_{CBO}^{\uparrow}$ (eV)	$\Delta E_{VBO}^{\uparrow}$ (eV)	$\Delta E_{CBO}^{\downarrow}$ (eV)	$\Delta E_{VBO}^{\downarrow}$ (eV)
HS3-Cr ₂ Cl ₃ S ₃ (S)/P $\uparrow$ -Ga ₂ O ₃	8.43	7.33	-1.49	-0.29	1.4	-0.28
HS3-Cr ₂ Cl ₃ S ₃ (S)/P $\downarrow$ -Ga ₂ O ₃	4.21	7.41	0.80	1.83	3.40	1.78
HS3-Cr ₂ Cl ₃ S ₃ (Cl)/P $\uparrow$ -Ga ₂ O ₃	8.69	6.20	-1.77	-0.55	1.14	-0.47
HS3-Cr ₂ Cl ₃ S ₃ (Cl)/P $\downarrow$ -Ga ₂ O ₃	4.89	6.49	-0.10	1.08	2.88	1.10

The work functions Φ_1 and Φ_2 , corresponding to the Ga₂O₃ side and the Cr₂Cl₃S₃ side, respectively.

The spin-resolved conduction-band and valence-band offsets are defined as:

$$\Delta E_{CBO}^{\uparrow/\downarrow} = E_{CBM}^{\uparrow/\downarrow}(Cr_2Cl_3S_3) - E_{CBM}^{\uparrow/\downarrow}(Ga_2O_3) \quad (1)$$

$$\Delta E_{VBO}^{\uparrow/\downarrow} = E_{VBM}^{\uparrow/\downarrow}(Cr_2Cl_3S_3) - E_{VBM}^{\uparrow/\downarrow}(Ga_2O_3) \quad (2)$$

Where $\uparrow$ and $\downarrow$ indicate the spin-up and spin-down channels, respectively, and are distinguished from the symbols P $\uparrow$ and P $\downarrow$, which represent the ferroelectric polarization direction of the Ga₂O₃ layer. $E_{CBM}^{\uparrow/\downarrow}(Cr_2Cl_3S_3)$ and $E_{VBM}^{\uparrow/\downarrow}(Cr_2Cl_3S_3)$ represent the spin-up/spin-down conduction band minimum (CBM) and valence band maximum (VBM) of the Cr₂Cl₃S₃ layer in the heterostructure, respectively, while $E_{CBM}^{\uparrow/\downarrow}(Ga_2O_3)$ and $E_{VBM}^{\uparrow/\downarrow}(Ga_2O_3)$ correspond to those of the Ga₂O₃ layer, using the Fermi level as a common reference.

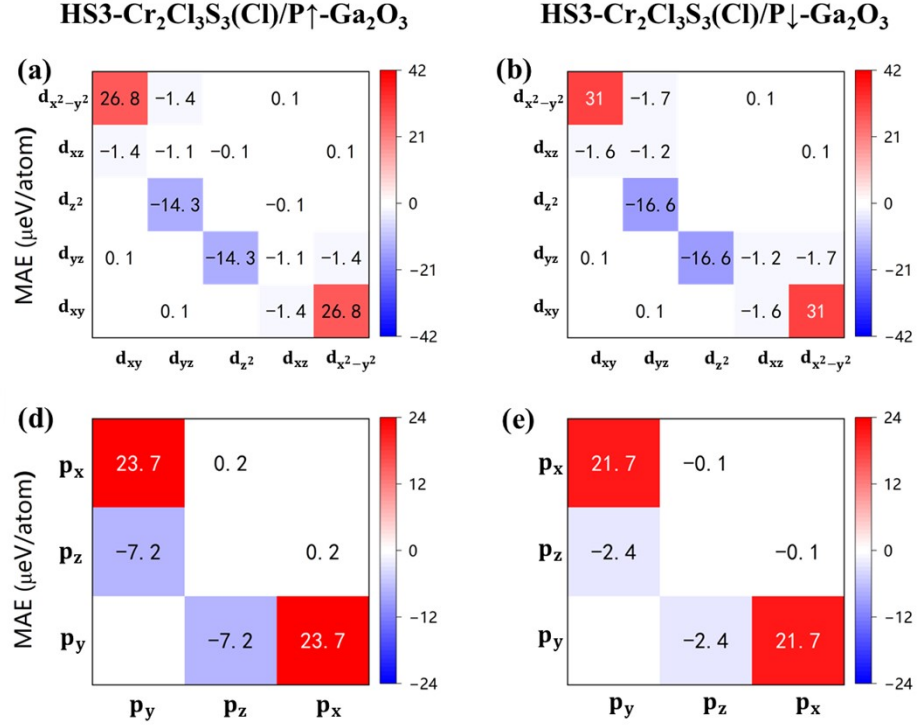


Fig. S8 The orbital-resolved MAE of Cr-*d* orbital for (a) HS3-Cr₂Cl₃S₃(Cl)/P↑-Ga₂O₃, (b) HS3-Cr₂Cl₃S₃(Cl)/P↓-Ga₂O₃, the orbital-resolved MAE of S-*p* orbital for (c) HS3-Cr₂Cl₃S₃(Cl)/P↑-Ga₂O₃, (d) HS3-Cr₂Cl₃S₃(Cl)/P↓-Ga₂O₃.